## Benha University Faculty of Engineering at Shoubra Electrical Engineering Department



EEC223: Electronics 1

3<sup>rd</sup> Term – Level 1 / Credit H

Sheet 01 - (Fall 2017)

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	OPTOELE SHE	CTRONIC	<u>cs</u>		1
	1. Calculate the effective electrons and holes in generation arsenide. Use the effective table below. Calculate the germanium, silicon and galtemperature (300 K). Repeate energy bandgap is independent	rmanium, ve masses intrinss llium ars at at 100 dent of t	silicon s provide ic carrie senide at	and gald in the r densi	llium ne ty in
3	by the values provided bel	Symbol Symbol	Germaniu	Silicon	Gallium
	Energy bandgap at 300 K	E (N)	m		Arsenide
		$E_{\rm g}\left({\rm eV}\right)$	0.66♣	1.12	1.424
1	Effective mass for density of states calculations	-			
	Electrons	$m_e/m_0$	0.56 2	1:08 17	0.067
	Holes	$m_h/m_0$			
	Effective density of states in the conduction band at 300 K	$N_{\rm C}$ (cm <sup>-3</sup> )	0.29	0.81	0.47.
	Effective density of states in the valence band at 300 K	$N_{\rm V}$ (cm <sup>-3</sup> )			
	Intrinsic carrier density at 300 K	$n_{\rm i}({\rm cm}^{-3})$		į	24 h
	Effective density of states in the conduction band at 100 ° C (373.15 K)	$N_{\rm C}$ (cm <sup>-3</sup> )		*	
	Effective density of states in the valence band at 100 ° C	$N_{\rm V}$ (cm <sup>-3</sup> )		1	
	Intrinsic carrier density at 100 ° C	$n_{\rm i}~({\rm cm}^{-3})$			
	h= 6.	ĥ	C= 1.1.		
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2- Calculate the position of the intrinsic energy level (intrinsic Fermi level  $E_{\rm Fi}$ ) relative to the midgap energy ( $E_{\rm c}$  +  $E_{\rm v}$ )/2 in germanium, silicon and gallium arsenide at 300 K. Repeat at T = 100 °C. Use the table and results of problem 1.

	Naı				Unit	Germani um	Silico	Gallium Arsenide
Solution	at	300	K	73 1 8	meV	12-8		
Solution	at	100	°C		meV			

3- Calculate the electron and hole density in germanium, silicon and gallium arsenide if the Fermi energy is 0.3 eV above the intrinsic Fermi energy level. Repeat for a Fermi energy which is 0.3 eV below the conduction band edge. Assume that  $T=300\,\mathrm{K}$ .

Name	Units Germanium		Silicon	Gallium Arsenide	
	cm <sup>-3</sup>				
	cm <sup>-3</sup>				
996 des sile sofetaye S	cm <sup>-3</sup>	oo Cand Pro			
	cm <sup>-3</sup>				

4 - A silicon wafer contains 10<sup>16</sup> cm<sup>-3</sup> electrons. Calculate the hole density and the position of the intrinsic Fermi energy and the Fermi energy at 300 K. Draw the corresponding band diagram to scale, indicating the conduction and valence band edge, the intrinsic Fermi energy level and the Fermi energy level.

( Use  $n_i = 10^{10} \text{ cm}^{-3}$  )